



13281 U.S.PTO  
032904

## SEMICONDUCTOR INTEGRATED CIRCUIT DEVICE

### BACKGROUND OF THE INVENTION

#### 1. Field of the Invention

5 This invention relates to a semiconductor integrated circuit, and more particularly to the configuration of an input/output circuit cell.

#### 2. Description of the related art

10 Generally, a flip-chip LSI has the following arrangement. Probing pads are arranged on the periphery of a chip. LSI peripheral circuit elements are arranged at a certain pitch in an area inside the probing pads. The LSI peripheral circuit elements include an input/output circuit cell, a power supply cell for an input/output circuit, and another power supply cell for an LSI internal logic circuit. A cell region for the LSI internal logic circuit and others is arranged inside the LSI peripheral circuit elements.

15 Further, on the surface of the chip, rearrangement wirings 5 for connecting the terminal pads and the LSI are arranged. The power supply lines for supplying a power supply voltage to drive these circuit elements include a power supply line for the LSI peripheral circuit located above the LSI peripheral circuit elements and another power supply line for the LSI internal logic circuit

arranged on the periphery of the LSI internal logic circuit. These power supply lines are electrically isolated from one another. Incidentally, a flip-chip package may be e.g. a package including a ball grid array (BGA) formed on a stiffener.

5       The timings of supplying a power supply voltage to each of the circuit elements within the LSI chip include a product testing timing as well as an operating timing. The product test includes a probing test at a wafer step and a test at a step of finished products after assembled. In the case of the test at a step of finished  
10      products after assembled, the product is operated at actual using frequency to test the input/output timing of a signal. In this case, for the purpose of evaluating the performance of the LSI chip in terms of its function and characteristic, both the LSI peripheral circuit element and the LSI internal logic circuit must be supplied  
15      with a sufficient power supply voltage.

In recent years, with the development of large-scaling of LSI, the degree of integration continues to increase. The number of input terminals also continues to increase. However, as regards the probing pads 2, the pad pitch is limited to about 120  $\mu$ m under the  
20      present conditions in view of the operability of probing test or bonding. This is one problem which obstructs high degree of integration.

This problem can be solved by a "staggered arrangement" in which a plurality of input/output circuits 3 are arranged at a pitch  
25      larger than half the pad pitch permitting bonding and a plurality

of probing pads 2 are arranged at a pitch larger than the pad pitch permitting bonding on the region on the side of the chip periphery and on the cell region 6 on the side of the chip center with respect to the plurality of input/output circuits, respectively.

5 (JP-A-10-284611)

However, the staggered arrangement requires a wider pad region than a "single row arrangement" and is structured so that an internal circuit is separated from the pad region, which provides an empty region. This led to a limitation in the reduction of the  
10 chip size.

As described above, the conventional semiconductor device is under the restriction in the arrangement of the probing pads. This has been a great problem which obstructs the high degree of integration.

15 Further, if the bit width of data is increased in order to perform the high speed data transfer, the number of input/output circuit cells is increased. This led to the problem of increasing the number of the power supply cells for the input/output circuits to supply the power to these input/output cells.

20

#### SUMMARY OF THE INVENTION

This invention has been accomplished under the circumstance described above. An object of this invention is to provide a semiconductor device which can be downsized and integrated to a high  
25 degree, and provides good and sure operability of probing test.

In order to attain the above object, this invention provides a semiconductor device including a rewiring characterized by mixedly comprising: an input/output (I/O) cell connected to a probing pad; and another input/output (I/O) cell having no probing pad.

5 Some input/output cells do not necessarily require the probing pad. Therefore, these input/output cells are not provided with the probing pad. For this reason, the pitch of arranging the cells can be increased by the extent of the input/output cells provided with no probing pad. Thus, the degree of integration can  
10 be improved without reducing packaging operability.

Further, the semiconductor device is characterized by further comprising a DRAM.

In the case of the DRAM, if it is found by the test using the probing pad that the characteristic is problematic, the memory array  
15 which is problematic in the characteristic is cut by breaking fuse and others, and connected to a spare redundant circuit so that it is relieved.

The semiconductor device is characterized by further comprising a fuse element. If it is found by the test using the probing pad that the characteristic is problematic, redundancy  
20 relief and characteristic adjustment (trimming) can be easily carried out by breaking the fuse element.

The semiconductor device may lack a probing pad on at least one side. If the input/output circuit(s) provided with no probing  
25 pad is arranged on this side, the entire area on this side where

the probing pad is formed can be reduced.

Further, in the semiconductor device according to this invention, the probing pads may be arranged in a staggered manner.

The input/output circuit cells are connected to the probing pads for probing test and connected to the terminal pads for external connection. In the test, from the probing pads, the monitoring of inputting or outputting a test pattern and power supply are carried out so that one of circuit blocks is subjected to probing test. In the testing at the stage of the final product after assembled, a signal and power are supplied from the package pins (terminals) connected to the terminal pads to drive the other of the circuit blocks.

Thus, in a probing test, a semiconductor device with a small IR drop can be provided without increasing the chip area.

The plurality of circuit blocks include an internal logic circuit block of a semiconductor integrated circuit and an input/output circuit block on the periphery. These circuit blocks are connected to the probing pads for probing test and terminal pads for external connection through the above input/output circuit cells.

In the testing, from the probing pads, the monitoring of inputting or outputting a test pattern and power supply are carried out so that one of the circuit blocks is subjected to probing test. In driving, a signal and power are supplied from the package connected to the terminal pads to drive the internal logic circuit block.

The probing pads are arranged on the surface of the

semiconductor integrated chip. The terminal pads are preferably connected to the internal logic circuit block connected to the input/output circuit cells through contacts formed in an insulating film overlying the probing pads.

5       The probing pads are preferably arranged on the surface of the edge of the semiconductor integrated circuit chip. This permits the chip area to be employed effectively.

10      The semiconductor integrated circuit device is preferably an flip-chip LSI provided with a rearrangement wiring on the surface and connected to a packaging substrate by face-down bonding.

#### BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a plan view for explaining an LSI according to the first embodiment of this invention.

15      Fig. 2 is a manufacturing flowchart of the LSI according to the first embodiment of this invention.

Fig. 3 is a manufacturing flowchart of the LSI according to the first embodiment of this invention.

20      Fig. 4 is a manufacturing flowchart of the LSI according to the first embodiment of this invention.

Fig. 5 is a manufacturing flowchart of the LSI according to the first embodiment of this invention.

Fig. 6 is a manufacturing flowchart of the LSI according to the first embodiment of this invention.

25      Fig. 7 is a manufacturing flowchart of the LSI according to

the second embodiment of this invention.

Fig. 8 is a manufacturing flowchart of the LSI according to the third embodiment of this invention.

Fig. 9 is a schematic view of a flip-chip LSI according to  
5 a prior art.

#### DESCRIPTION OF THE PREFERRED EMBODIMENTS

Now referring to the drawings, an explanation will be given  
of an embodiment of this invention. First, the arrangement of the  
10 cells and their operation will be explained.

(Embodiment 1)

An LSI chip 1 according to this invention, as seen from Fig.  
1 which is a schematic view thereof and Fig. 5 which is a sectional  
15 view of the main part, includes probing pads 2 on the outer periphery  
of the chip; first input/output circuits 3S connected to the probing  
pads, respectively, inside them; second input/output circuit cells  
3n connected between these input/output cells and provided with no  
probing pad; rearrangement wirings 5 layered on these first and  
20 second input/output cells; and terminal pads formed on the  
rearrangement wirings and an element region 6.

It should be noted that the element region constitutes a DRAM.

An explanation will be given of a manufacturing process of  
the LSI chip 1.

25 First, as seen from Fig. 2, , input/output cells and power

supply cells 1a are formed in the I/O cell regions in the surface of a silicon substrate 1, and DRAMs 1b are formed on an element region (internal circuit region R2). A first layer aluminum wiring is formed for these DRAMs so as to be brought into contact with contacts 12 formed in an interlayer insulating film 11. A second layer aluminum wiring is formed through contacts 13 so as to constitute probing pads 2 and rearrangement wiring pads 2P. The regions among wiring patterns and among wiring layers are covered with an interlayer insulating film.

10 As seen from Fig. 3, contact holes are formed in the interlayer insulating layer to expose the probing pads 2. Using the probes, a probing test is carried out.

If the probing test determines that the DRAM characteristic is problematic, a fuse layer is cut as shown in Fig. 4.

15 Further, as seen from Fig. 5, an insulating protective film 21 is applied to protect the surface.

Finally, contacts are made on the insulating film 21 to form rearrangement wirings 5. Solder bumps 4 are formed through barrier metals 9.

20 In accordance with such a configuration, only the input/output circuits 3S which require the probing pads are provided with probing pads, whereas the other input/output circuit are not provided with no probing pad. For this reason, in the semiconductor device according to this invention, the element area can be reduced  
25 without reducing the performance.

(Embodiment 2)

Incidentally, in the previous embodiment, the probing pad 2 was formed for every other input/output circuit. In this second embodiment, as seen from Fig. 7, one probing pad 2 is connected for  
5 four input/output circuits.

In this configuration, the width of the input/output cell is reduced to half in that in the first embodiment. Thus, the number of bumps is increased so that the number of terminals usable in the test after sealing can be increased, thereby realizing "high speed  
10 multi-pin".

(Embodiment 3)

In the first embodiment, the probing pad 2 was formed for every other input/output circuit in each of four sides. On the other  
15 hand, in this third embodiment, as seen from Fig. 8, in three sides of the four sides, the probing pad 2 is formed for every other input/output circuit, whereas in the remaining one side, no probing is formed. In accordance with this embodiment, the cell area can be greatly reduced.

20 In accordance with this invention, a down-sized LSI can be formed without deteriorating its performance.